


INVENTORS

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TITLE

Substrate Treatment Method

TECHNICAL FIELD AND INDUSTRIAL APPLICABILITY OF THE INVENTION

10 The present invention relates to a method for etching composite material
substrates and other substrates, and also is directed to a method for applying wear-
resistant and other coatings to composite material substrates and other substrates. The
present invention also relates to composite material substrates, which are comprised of
particles of a hard constituent phase in a binder material phase that binds together the
15 hard constituent particles, having wear-resistant and other coatings. The present
invention finds application in any field in which it is advantageous to enhance the
adhesion of a wear-resistant and other types of coatings to substrates. Examples of
fields of application of the present invention include the manufacture and treatment of
dies used in metal stamping, punching, threading, and blanking, and the manufacture
20 and treatment of metal cutting inserts used in milling, turning, drilling, boring, and
other metal removal operations.

BACKGROUND OF THE INVENTION

Composite materials comprised of particles of a hard constituent phase and a
25 binder phase binding the particles together are common and are referred to as

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“composite materials” or “composite substrates” hereinafter. Such materials also may be referred to as “cemented” composite materials and include, for example, ceramics, cermets, and cemented carbides. Cemented carbides, include, for example, materials composed of a hard particulate material such as, for example, particles of one or more
5 of tungsten carbide (WC), titanium carbide (TiC), titanium carbonitride (TiCN), tantalum carbide (TaC), tantalum nitride (TaN), niobium carbide (NbC), niobium nitride (NbN), zirconium carbide (ZrC), zirconium nitride (ZrN), hafnium carbide (HfC), and hafnium nitride (HfN) cemented together by a binder phase that is composed predominantly of one or more of cobalt, nickel, and iron.

10 Metal cutting inserts fabricated from composite materials are commonly used in chip cutting machining of metals in the metal machining industry. Metal cutting inserts are commonly fabricated from particles of metal carbide, usually tungsten carbide with the addition of carbides of other metals such as, for example, niobium, titanium, tantalum, and a metallic binder phase of cobalt or nickel. The carbide
15 materials provide high strength but still may wear quickly when used in, for example, milling and other metal machining operations. By depositing a thin layer of wear-resistant material on the working surfaces of cemented carbide cutting inserts it is possible to increase the wear-resistance of the inserts without adversely affecting toughness. Commonly used wear-resistant cemented carbide insert coatings include,
20 for example, TiC, TiN, TiCN, and Al_2O_3 . Such wear-resistant coatings reduce the erosion and corrosion of the inserts' binder material.

The utility of coated composite materials such as coated cemented carbides is limited by the strength of adhesion of the wear-resistant coating to the composite

material. Absence of strong adhesion between wear-resistant coatings and metal cutting inserts causes delamination of the coatings from the inserts, decreasing the inserts' service life. The presence of cobalt at the inserts' surfaces also increases the tendency of the coatings and substrates to experience delamination during use.

- 5 Accordingly, it would be advantageous to provide a novel method for increasing the adhesion of wear-resistant coatings to composite materials. More broadly, it would be advantageous to enhance the adhesion of wear-resistant coatings and other types of coatings to composite material and other types of substrates.

SUMMARY OF THE INVENTION

10 The present invention provides a method for removing a portion of the binder phase from a substrate that is composed of at least particles of a first phase joined together by the binder phase. The present method includes the step of etching at least a portion of a surface of the substrate by contacting the surface with a gas flow that is composed of at least an etchant gas and a second gas for
15 a time period that will allow for removal of the desired amount of binder phase. The second gas comprises one or more gases that will not react with the substrate or the removed binder material and that will not alter the oxidation state of the substrate during the etching step. Preferably, the second
20 gas is one or more gases that will not react with the substrate or the removed portion of binder material to form deposits of a phase of W_xCo_yC (wherein $x = 3-9$ and $y = 2-6$), also referred to herein as an η (eta) phase, on the substrate.

skill in the substrate coating and treatment arts will comprehend additional composite materials to which the present invention may be applied.

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The present invention also is directed to a method for applying a coating to at least a portion of the surface of a substrate, preferably a composite substrate that

5 includes hard constituent material particles joined together by a binder. The method is carried out by removing a portion of the binder from a surface of the substrate by contacting the surface with a gas flow including an etchant gas and a second gas for a period of time that will remove the desired portion of binder. The surface etching effect of the etchant gas provides an etched surface on the substrate, and the etched

10 surface will include voids produced as the binder is etched away from between hard constituent particles. The second gas is one or more gases that will not react with the substrate or the portion of the binder removed from the substrate, and that will not change the oxidation state of the substrate during the etching process. Preferably, the second gas will not react during the etching process to form eta phase within the voids

15 etched in the substrate's surface. In a subsequent step of the method, a coating is applied to at least a portion of the etched surface. At least a portion of the coating is deposited within at least a portion of voids on the etched surface created by removal.

Thus, the etching step of the present invention may be preceded or followed by one or more additional steps, including, for example, the step of depositing a coating

20 on the etched surface of the substrate produced by the etching step. Because the coating infiltrates voids in the etched surface of the substrate that have been produced by removal of binder material during the etching step, the adhesion of the coating to the substrate is enhanced. Preferably, the coating is one that enhances the wear

resistance of the substrate, but it also may be selected from any other conventional substrate coating. Possible wear-resistant coatings that may be applied in the coating step of the present method include those composed of, for example, one or more of TiC, TiN, TiCN, diamond, Al₂O₃, MT-milling coating (described in detail below),
5 TiAlN, HfN, HfCN, HfC, ZrN, ZrC, ZrCN, BC, Ti₂B, MoS, Cr₃C₂, CrN, CrCN, and CN.

The present invention is also directed to substrates that have been produced by the method of the present invention. For example, such substrates within the scope of the invention may have an etched surface produced by the foregoing etching step, and
10 also may have a coating, wear-resistant or otherwise, which at least partially infiltrates voids produced in the substrate's surface by the etching step of the invention. In particular, the present invention is directed to a substrate composed of a composite material including particles of a hard constituent material and a binder material. The substrate includes an etched surface portion having voids thereon produced by
15 removing a portion of the binder material therefrom by contacting the surface portion with concurrent flows of at least a suitable etchant gas and a second gas. The second gas must be incapable of reacting with the substrate or the removed binder material or changing the oxidation state of the substrate during etching of the binder material. A coating may be adhered to at least a portion of the etched surface portion of the
20 substrate, and at least a portion of the coating is deposited within at least a portion of the voids provided in the etched surface portion.

Examples of applications of the method of the present invention include the manufacture and treatment of wear resistant cutting inserts, dies, punches, and other

elements used in applications such as: metal stamping, punching, threading, blanking, milling, turning, drilling, boring, and other metal removal operations; mining and oil drilling, including fabricating or treating mining and drilling bits used in long wall and coal boring miners, tricone, percussive and rooftop drilling bits, road planing and other like applications; wood working applications, including fabricating or treating bits and blades used in sawing, planing, routing, shaping, and other woodworking applications; drawing, heading, and back extrusion, including the fabrication and treatment of punches and dies used in such applications; rod mill rolls; and high corrosion environments. An example of a specific application of the present invention is in the manufacture and treatment of items made from tungsten-based alloys containing iron, nickel, copper and/or cobalt. Such items include, for example, aircraft weights, electrical contact points, and electrodes.

The reader will appreciate the foregoing details and advantages of the present invention, as well as others, upon consideration of the following detailed description of the invention. The reader also may comprehend such additional details and advantages of the present invention upon practicing the invention.

BRIEF DESCRIPTION OF THE DRAWINGS

The features and advantages of the present invention may be better understood by reference to the accompanying figures, in which:

Figure 1 is a photomicrograph of a prepared section of a metal cutting insert composed of SD-5 material coated with wear-resistant MT-milling (moderate temperature milling and turning) coating by the method of the present invention;

Figures 11a-11d are photomicrographs of a prepared section of a heavy metal part containing tungsten metal particles (about 90 weight percent of the part's total weight) suspended in an iron/nickel binder (about 10 weight percent of the part's total weight) that was etched and coated with an MT-milling coating by the method of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

An aspect of the present invention is directed to a method for applying a coating, preferably a wear-resistant coating, to a composite material substrate. The composite material substrate includes a phase of a hard constituent and also includes a binder phase that is predominantly one or more of cobalt, nickel, and iron. The present inventors have discovered that the method of the invention enhances the adherence of the coating to the composite material substrate and inhibits delamination of the coating. The present invention also is directed to etched and etched/coated substrates prepared by the method of the present invention.

It is believed that in relation to the known composite material substrate coating methods, the present method improves adhesion between composite material substrates and wear-resistant coatings by allowing the coatings to infiltrate the surface of the substrate. To accomplish this, a portion of the binder phase of a surface region of the composite material substrate is removed by a novel etching procedure, preferably to a depth in the range of about 3 to about 15 microns (inclusive), while leaving the hard constituent particles in the surface region substantially intact. Wear-resistant coatings applied to composite material substrates that have been etched by

the present method infiltrate the voids in the surface region created by removal of the binder phase. The infiltration of the coating is believed to increase the adhesive strength between the coating and the composite material substrate. It has been found that the enhanced adhesion between coatings and composite material substrates

5 achieved by the present method reduces differences in thermal expansion between the substrates and coatings, improves the coatings' resistance to deformation, increases coating wear resistance, and reduces the occurrence of thermal cracking.

As used herein, "composite material" refers to a material, in any form, that includes at least particles of a phase of a hard constituent material and a phase of a

10 binder material that binds together the hard constituent particles. The composite material may be, for example, cemented carbides and cermets. The binder material of the present composite material may include one or a combination of more than one of cobalt, nickel, copper, and iron. In addition to cobalt, nickel, copper, and/or iron, the binder material may include other elements and compounds as are known in the art.

15 Such other elements include, for example, those within Group VIII of the periodic table (elements having atomic numbers 26-28, 44-46, and 76-78), tungsten, zinc, and rhenium. The particles of the hard constituent may be, for example, particles composed of:

- one or more carbide materials selected from tungsten carbide (WC), titanium carbide (TiC), tantalum carbide (TaC), niobium carbide (NbC),
- 20 vanadium carbide (VC), chromium carbide (Cr_3C_2), molybdenum carbide (MoC), and iron carbide (FeC);

- one or more carbonitrides and/or nitrides of one or more of the refractory metals, including carbonitrides of one or more of W, Ti, Ta, Nb, V, Cr, Mo, and Fe;
- one or more oxides and/or borides of one or more of aluminum, zirconium, and magnesium; and
- one or more of tungsten, molybdenum-based materials, and tungsten-based materials.

As used herein, the term "refractory metals" refers to metals having an extremely high melting point, for example, W, Mo, Ta, Nb, Cr, V, Re, Ti, Pt, and Zr.

10 In addition to enhancing the adhesion of wear-resistant coatings to the foregoing composite materials, it is believed that the method of the present invention also may be used to enhance the adhesion of wear-resistant and other types of coatings to other types of materials, including, for example, heavy metals, sialons, Si_3N_4 , and composite ceramics, that have a phase that may be etched by the present method. The

15 identities of such other materials may be readily determined by those having ordinary skill in the substrate coating arts. Moreover, although the following examples are directed to the application of wear-resistant coatings to composite material and other substrates, it will be understood that the present method also may be used to better adhere other types of coatings to such substrates. Such other coatings include

20 coatings that impart desirable properties to the substrate surface, such as, for example, coatings that enhance the substrate's resistance to corrosion, including oxidation, or that provide a particular surface appearance to the substrate. The identities of other coatings that may be applied using the method of the present invention will be readily

apparent to those having ordinary skill in the substrate coating arts once apprised of the invention.

In one embodiment of the method of the present invention, the method generally includes at least the following steps:

- 5 1. Place a composite material substrate to be coated in a chamber of a chemical vapor deposition furnace.
2. Etch away all or a portion of the binder phase in a surface region of the composite material substrate to a depth of about 3 microns to about 15 microns by contacting the surface region with a mixture comprising an etchant gas and an inert gas such as nitrogen gas. (The etchant gas may be selected from, for example, gaseous hydrogen chloride, gaseous H_2F_2 , or the gaseous form of any of the Group VIIA elements. Other suitable etchant gases will be apparent to those of ordinary skill in the art or may be determined by such persons without undue experimentation, and it will be understood that the identity of such suitable alternative etchant gases will depend on the particular composition of the material that is to be etched. The gaseous mixture is applied to the surface of the material to be etched under conditions and for a time suitable to remove the desired amount of binder phase from the material. Such conditions and times may be readily ascertained, without significant experimentation, by those having ordinary skill in the substrate coating arts.)

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3. Purge the chamber with a flow of an inert gas ("inert" meaning that it will not react with the binder material) such as, for example, nitrogen, argon, or helium gas.
4. Coat the etched region of the composite material substrate with at least one layer of a wear-resistant material by introducing a reactive gaseous form of the wear-resistant material into the chamber under conditions that will result in the deposition of the wear-resistant material on the etched region. (Such conditions, which generally include such parameters as reactive gas flow rates, chamber gas pressure, chamber and/or substrate temperature, and reaction time) may be readily ascertained by those having ordinary skill in the substrate coating arts once apprised of the present invention.

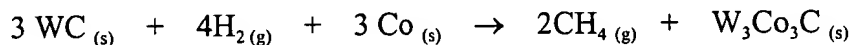
Although the method of the invention is disclosed above as being carried out in a chamber of a chemical vapor deposition (CVD) furnace, it will be understood that the etching step may be carried out in any chamber that is sealed from the environment and into which a flow of the gases may be introduced. An advantage of carrying out the process in a CVD furnace is that the etching, purging, and coating steps may be carried out sequentially in the furnace chamber without the need to move the composite materials from one chamber to another during the process. Thus, the method of the invention may be programmed as a complete cycle in the CVD furnace and accomplished in one run. This feature of the invention provides a distinct advantage over procedures wherein a liquid solution etchant is used to remove binder phase material because such liquid solutions cannot be introduced into the same

chamber employed to coat the substrate by a CVD or PVD process. Also, it has been found that the substrate may be kept cleaner and the depth of etching may be better controlled when using a gaseous etchant as opposed to a liquid etchant.

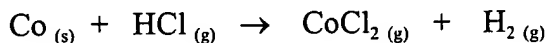
The step of etching binder phase from the composite material substrate preferably should remove binder material to a depth of about 3 to about 15 microns and more preferably about 4 to about 6 microns, into the substrate surface. Too shallow an etching depth does not provide a significant enhancement in coating adhesion. Too great an etching depth weakens the surface of the substrate. Etching time may be varied to account for differences in the susceptibility of the particular binder phase to be removed by the etchant gases. Those having ordinary skill in the substrate coating arts may readily determine the etching time necessary to provide a desired depth of etching for a particular substrate. The substrate temperature at which the etching step should be carried out to remove the desired amount of binder material also will depend upon the character of the binder, but may be readily determined.

Deposits of a phase of W_xCo_yC (wherein $x = 3-9$ and $y = 2-6$), also known as η (eta) phase, may form on the surface of composite material substrates. Eta phase is a hard and brittle carbon-deficient phase that may easily fracture and may be produced when etching substrates that include tungsten, carbon, and cobalt. The presence of eta phase significantly degrades the properties of composite material substrates used in material removal (*i.e.*, cutting, drilling, threading, boring, etc.) applications and, therefore, the generation of eta phase preferably should be avoided during the etching and coating of composite material substrates and other substrates by appropriately adjusting the etching and coating conditions. For example, relative to composite

material substrates including nickel binder, composite material substrates having cobalt binder should be etched at lower substrate temperatures in order to inhibit the formation of eta phase on the surface of the substrate. The inventors also have determined that if hydrogen gas is present during an etching step employing a gaseous etchant, the hydrogen may combine with any carbon present as WC and any cobalt within the substrate material and will thereby make the WC deficient in carbon, resulting in formation of an eta phase. One possible reaction representative of formation of an eta phase is as follows:



- 10 The eta phase does not convert to CoCl_2 , as is required for the precursor elements of the eta phase to leave the substrate surface as a gas. The inventors have concluded that formation of eta phase is significantly inhibited when using nitrogen or certain other gases in substitution for hydrogen gas used in conjunction with etchant gas during the etching step. A representation of a possible reaction occurring during etching of a cobalt-containing composite material by a hydrogen chloride etchant gas, and wherein the etchant gas is not applied to the material in combination with hydrogen gas, is believed to be as follows:



- 20 The CoCl_2 is a gaseous product that is swept from the coating furnace during the purging step.

Accordingly, the inventors have discovered that the step of etching a substrate including tungsten, carbon, and a binder phase including cobalt will not be satisfactorily accomplished if the gaseous etchant mixture includes hydrogen gas.

For example, when etching binder phase from a composite material cutting insert composed of tungsten carbide particles in a binder composed predominantly of cobalt using a gaseous etchant mixture of hydrogen chloride and hydrogen gases, cobalt residue remains in the voids etched between the tungsten carbide particles and the undesirable eta phase may form, significantly reducing substrate toughness. The inventors have found that nitrogen gas may be advantageously substituted for hydrogen gas to prevent formation of eta phase. More broadly, to better ensure removal of etched binder material so as to avoid formation of eta phase on substrate surfaces, gases that may be substituted for hydrogen gas in the gaseous mixture used in the substrate etching step include those selected from one or more of nitrogen gas and other gases that do not react with the substrate or removed binder and that do not change the oxidation state of the substrate. Such other gases are believed to include, for example, helium, argon, and neon gases.

The foregoing representations of reactions that may occur during the etching process are provided only to better illustrate possible reaction mechanisms, and should not be considered to in any way limit the scope of the invention.

As discussed above, the etchant gas that may be used in the etching step of the method of the present invention may be any gas that will suitably remove the desired depth of binder phase in a surface region of the composite material substrate that is being etched. Such etchant gases include, for example, HCl gas, H_2F_2 gas, and the gaseous form of any of the Group VIIA elements in the periodic table of the elements.

The purging step occurring subsequent to the etching step is necessary to remove any products of the etching reaction and any etchant remaining in the

chamber, and to reduce any explosion hazard. Any gas or combination of gases that will suitably remove the reactant products and remaining etchant gases and that will not react with the binder or hard particle constituents of the composite material may be used as the purging gas. Suitable purging gases include, for example, one or more
5 of nitrogen, helium, and argon gases.

Once etched, the substrate may then be coated with a wear-resistant or other coating material by any conventional composite substrate coating process. Such processes include, for example, CVD, PVD, plasma arc, and super lattice processes. Still other composite material coating procedures will be readily apparent to those of
10 ordinary skill in the substrate coating arts. All such other suitable coating processes may be used in the present method subsequent to the gas etching procedure. Any coating process used to deposit wear-resistant material on a composite material substrate etched by the procedure of the present method is carried out under conditions by which the wear-resistant material may at least partially infiltrate the
15 voids in the composite material created by removal of the binder material. One of ordinary skill may readily determine such conditions without undue experimentation.

On a basic level, the present invention also is directed to a method for removing binder material from a region of a composite material, and the inventive method need not include the subsequent coating step. A composite substrate having a
20 roughened surface may be produced by such a method. Roughened composite substrates may be used in a variety of known applications, including, for example, ball point pen balls, wherein a roughened surface provides enhanced traction.

Additionally, substrates may be etched by the present method and then coated at some

later time and/or at a different facility, rather than in a single procedure in which the etching and coating steps are combined. One example of a coating that may be applied in a procedure removed in time from the etching procedure and/or at another facility is a diamond coating.

- 5 Following are actual examples illustrating embodiments of the method of the present invention. The following examples are illustrative examples only, and should not be considered to in any way limit the scope of the present invention.

Example 1

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10 A Bernex 250 CVD coating furnace was prepared by introducing into the coating chamber of the furnace a 10 l/min (liters/minute) flow of hydrogen gas to establish a 200 mbar hydrogen gas pressure within the chamber. The chamber was then heated to 850°C. A cemented carbide substrate composed of H-91 grade material available from Stellram, LaVergne, Tennessee, was placed in the prepared furnace chamber and the chamber atmosphere was heated to 850°. H-91 grade
15 material is composed of 88.5 weight percent tungsten carbide, 11.0 weight percent cobalt, and 0.5 weight percent of a mixture of TiC, TaC, and NbC. The material exhibits a hardness of 89.7 HRA, 14.40 g/cc density, and a transverse rupture strength of approximately 389,000 psi.

20 The flow of hydrogen gas was then stopped, and a concurrent flow of 20 l/min nitrogen gas and 1 l/min hydrogen chloride gas was introduced into the chamber to provide a chamber pressure of 800 mbar. Binder was etched to a depth of approximately 5 microns into the substrate's surface by the running the concurrent N₂/HCl gas flow into the chamber for 25 minutes, and then discontinuing the flow of

HCl gas. While maintaining the chamber atmosphere at 850°C, the chamber was then purged for 15 minutes by continuing the 20 l/min flow of N₂ gas while establishing a 60 mbar chamber pressure.

After purging the chamber, and without removing the etched substrate from the chamber, the etched substrate was coated with a moderate temperature milling and turning coating (referred to herein as "MT-milling coating"), which is a multi-layer insert coating consisting of two TiN layers of approximately 1 micron with a TiCN layer of approximately 3 microns disposed between the two TiN layers. The MT-milling coating was deposited on the substrate by introducing into the furnace chamber flows of gases that will produce coatings of TiN, TiCN, and then TiN, in that order, as follows.

Before the coating procedure began, the chamber atmosphere was heated to 920°C and the chamber pressure was reset to 160 mbar. After that pressure was established, a first TiN layer was provided on the substrate by initiating a 9 l/min nitrogen gas flow, increasing the hydrogen gas flow to 14 l/min, and initiating a 2.1 ml/min flow of TiCl₄ gas. The concurrent flows of the three gases were allowed to proceed for 60 minutes while the chamber pressure was maintained at approximately 160 millibars. During the 60-minute period, the furnace temperature was lowered 5-10°C every fifteen minutes so as to be at approximately 895°C at the end of the period.

The interposed TiCN coating was produced by lowering the nitrogen gas flow to 8 l/min, and then resetting chamber pressure to 60 mbar. The TiCl₄ gas flow was then raised to 2.4 ml/min. Once all flows were constant, a flow of CH₃CN gas

generated by vaporizing a 0.3-0.4 ml/min flow of liquid CH_3CN flow was initiated. The concurrent gas flows were continued for 2 hours, during the first hour of which the furnace temperature was reduced to 870°C . At the end of the 2-hour period, the flows of CH_3CN and TiCl_4 gases were discontinued.

- 5 To prepare for deposition of the second TiN layer, the flow of nitrogen gas was discontinued, chamber pressure was set to 500 mbar, hydrogen gas flow was reset to 12 l/min, and furnace temperature was set at 940°C . When that temperature was reached, the pressure was set to 60 mbar, hydrogen gas flow was reset to 10.5 l/min, nitrogen gas flow was reset to 4.5 l/min, and TiCl_4 gas flow was reset to 1.4 ml/min.
- 10 On reaching the target 1.4 l/min TiCl_4 gas flow rate, the flows were continued at temperature for 30 minutes, at which time the pressure was reset to 800 mbar and the gas flows were continued for an additional 30 minutes. The furnace was then purged by shutting off the TiCl_4 gas flow, resetting chamber pressure to 600 mbar, raising hydrogen gas flow to 12 l/min, and lowering nitrogen gas flow to 3.5 l/min. The reset
- 15 gas flows were continued for fifteen minutes. The furnace was then subjected to a cool down procedure.

It was observed that the MT-milling coating infiltrated at least a portion of the voids etched in the substrate's surface.

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Example 2

The Bernex 250 CVD furnace used in Example 1 was prepared using the procedure described in that example. A cermet substrate composed of SD-5 material, but having the same size and shape as the substrate in Example 1, was placed into the

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coating furnace and the furnace atmosphere was heated to 920°C. SD-5 material is a cermet grade material available from Stellram, LaVergne, Tennessee, and is composed of TiCN and Mo₂C particles in a Co/Ni binder. SD-5 material has the approximate elemental composition 45.2 Ti, 22.6 Mo, 10.9 C, 2.3 N, 19.0 Ni, and exhibits the following approximate mechanical properties: 91.8 HRA hardness, 6.30 g/cc density, and a transverse rupture strength of 300,000 psi. After heating the furnace atmosphere to 920°C, the Co/Ni binder was then etched to a depth of 5 microns from the substrate's surface using concurrent flows of hydrogen chloride and nitrogen gases at the flow rates, pressure, and reaction time used in Example 1 above. The furnace chamber was then purged using a 20 l/min flow of N₂ gas for 15 minutes at a chamber pressure of 60 millibars. The etched composite was then coated with an MT-milling coating using the procedure of Example 1. The MT-milling coating infiltrated the etched voids to a depth of 5 microns ± approximately 1 micron, and with approximately 1 micron of the coating disposed above the substrate's surface.

15

Example 3

Three Stellram cutting inserts of type SEKN-42-AF4B composed of SD-5 material (as described in Example 2) were first etched and then coated with the MT-milling coating by the following procedure.

20 A CVD furnace chamber was prepared using the procedure described in Example 1. The SD-5 cutting inserts were then inserted into the furnace chamber and were etched using the procedure of Example 2. Once etched, the inserts were coated with MT-milling coating by the procedure of Example 1. The MT-milling coating

produced on the etched inserts by the foregoing procedure was approximately 5 microns in thickness and the surface TiN layer infiltrated the voids etched in the inserts' surfaces. Approximately 5 microns of the coating extended above the inserts' surfaces. Figure 1 is a photomicrograph (2040X) of a prepared cross-section through the surface of one of the etched and coated SD-5 inserts. The photomicrograph shows the infiltration of the MT-milling coating into the voids etched in the insert surface. The infiltration of the coating into the voids increased the adherence of the coating to the insert and improved the thermal shock resistance of the coating.

The three etched and coated SD-5 inserts and three inserts of the same type that were unetched and uncoated were inserted at one time into a six-insert Teledyne (Laverne, Tennessee) HSM-3E4-45 EZ shear cutter that was then installed on a 2 H.P. Bridgeport milling machine and tested under the following milling conditions:

8620 steel at 20-25 Rockwell C hardness
800 surface feet per minute
0.050 inch depth of cut
0.004 - 0.005 inches per tooth (feed rate)
16.5 inch length of cut
2.5 inch width of cut

The SD-5 inserts were pulled and inspected after every two 16.5 inch milling passes. After the initial two passes, one uncoated SD-5 insert had one thermal crack started and the five remaining SD-5 inserts did not exhibit thermal cracks. After ten passes, all three unetched/uncoated SD-5 inserts exhibited one or more thermal cracks while only one etched and coated SD-5 insert exhibited a single thermal crack. Milling testing was concluded after 18 passes, at which point each unetched/uncoated insert exhibited 2-4 thermal cracks on their used edges, while only one thermal crack existed in one etched and coated insert. The conditions of an edge surface of each of

the three etched/coated SD-5 inserts after 10 and 18 passes are shown in Figures 2a-c and 3a-c, respectively. The used edge conditions of the three unetched/uncoated SD-5 inserts after 10 and 18 passes are shown in Figures 4a-c and 5a-c, respectively.

Example 4

5 Three Stellram SEKN-42-AF4B cutting inserts composed of T-14 material were etched and then coated with an MT-milling coating by the method used in Example 3. T-14 material is a milling grade material available from Stellram (LaVergne, Tennessee) having a nominal composition composed of 70 weight percent tungsten carbide and 20 weight percent of a combination of tantalum carbide, 10 niobium, and titanium carbide. Particles of the foregoing material are bound together by a cobalt binder that is 10 weight percent of the total weight of the material. T-14 material typically exhibits a hardness of 91.20 HRA, 12.43 g/cc density, and an average transverse rupture strength of 296,000 psi.

The three etched and coated T-14 inserts and three unetched and uncoated T- 15 14 inserts of the same type were inserted at one time into a six-insert HSM-3E4-45 EZ shear cutter, installed on a 2 H.P. Bridgeport milling machine, and tested under the following milling conditions:

20 4140 steel at 40-45 Rockwell C hardness
500 surface feet per minute
0.050 inch depth of cut
0.004 - 0.005 inch per tooth (feed rate)
14 inch length of cut
2.5 inch width of cut

25 After four passes under the above conditions, the depth-of-cut regions of the etched and coated T-14 inserts showed no evidence of thermal cracking or deformation as examined under a 40X microscope. After four passes all unetched and

uncoated T-14 inserts exhibited numerous thermal cracks with one insert at the thermal crack breakout stage. As used herein, "thermal crack breakout" is the point at which two or more thermal cracks connect and just before the insert surface fractures. Photomicrographs showing the condition of the depth-of-cut region of the three etched and coated T-14 inserts and the three unetched and uncoated T-14 inserts are shown in Figures 6a-c and 7a-c, respectively. The test demonstrated that using the present invention's method to etch composite substrates with cobalt binder to a 10 micron depth and then coating the substrates provides for a coated insert showing significant edge strength and enhanced resistance to coating/edge delamination, coating spalling, and edge fracture. Results similar to the SD-5 insert milling tests of Example 3 were achieved in that the T-14 substrates etched and coated by the present invention's method provide an increased resistance to thermal cracking of the cobalt-based material.

Example 5

Stellram SEKN-42-AF4B type cutting inserts composed of H-91 grade material were obtained. Half of the H-91 inserts were coated with MT-mill coating in a Bernex 325 furnace using an automated procedure substantially similar to the above-described MT-milling coating procedure so as to provide a layered coating on the inserts composed of approximately 1 micron TiN, approximately 3 microns TiCN, and then 1 micron TiN, all such thicknesses being approximate. The remaining H-91 grade inserts were etched in a Bernex 250 CVD furnace using the procedure of Example 1 and the etched inserts were then MT-milling coated in the furnace by the

procedure described in Example 3. Actual total MT-milling coating thicknesses were determined to be 6.2 microns for the unetched/coated inserts and 5.4 microns for the etched/coated inserts. A photomicrograph of the coated surface of one of the etched and coated H-91 inserts is shown in Figure 8. The figure demonstrates the infiltration of the coating into the etched inserts' surfaces.

Single etched/coated or unetched/coated H-91 inserts were installed on a seven-insert Teledyne HSM-5E4-45 5-inch diameter EZ shear cutter, installed on a 25 H.P. Kearney-Trecker milling machine, and tested under the following milling conditions:

10	ASTM A536 (F-33100 unified UNS) nodular cast iron
	875 surface feet per minute
	0.125 inch depth of cut
	0.008 feet per tooth
	20 inch length of cut
15	4 inch width of cut

Each insert was pulled after one pass and examined. After one pass, each of the tested unetched/coated inserts exhibited 6-7 thermal cracks, while the tested inserts that had been etched and coated by the method of the present invention exhibited only a single thermal crack. 30X photomicrographs of an etched/coated H-91 insert after one milling pass and an unetched/coated insert after one milling pass are provided as Figures 9 and 10, respectively.

This example 5 compared inserts composed of identical base materials and identical coatings, with the only significant difference being that the test samples of one set were first etched by the present method and the MT-milling coating had infiltrated the resulting interstices in the inserts' surfaces. The etched and infiltrated

inserts exhibited significantly increased resistance to thermal cracking relative to the unetched coated inserts.

Example 6

5 A heavy metal part containing 90 weight percent tungsten metal particles suspended in 10 weight percent of an iron/nickel binder was etched and coated with an MT-milling coating using the procedures of the invention as generally described in the foregoing examples involving insert composed of SD-5 material. 21X photomicrographs of sections of the etched and coated metal part taken through the coated surface are shown in Figures 11a-11d. The photomicrographs shown the infiltration of the coating into the voids etched in the metal part's iron-nickel binder. 10

 In each of the foregoing Examples 1-5, all composite material substrates that were etched using the method of the present invention failed to show evidence of the formation of an eta phase. 15

 Those of ordinary skill in the substrate coating and treatment arts will appreciate that various modifications and changes in the details of the invention that has been disclosed herein may be made without detracting from the advantages provided by the invention, and it will be understood that all such changes and modifications remain within the principle and scope of the invention as expressed in the appended claims. 20